In the Claims

Please replace all prior versions, and listings, of claims in the application with the following list of claims:

1.-5. Canceled

6. (Previously presented) A projection screen, comprising:

a substrate; and

a light selective reflection layer which is formed on one side of the substrate, which has reflection characteristics in relation to lights in specific wavelength bands, and which has absorption characteristics in relation to lights other than the lights in the specific wavelength bands, wherein the light selective reflection layer is an optical multilayer film made by alternately layering metal films and dielectric film, and wherein the light selective reflection layer is made by sequentially layering a first metal film made of Nb, a first dielectric film made of Nb_2O_5, a second metal film made of Nb, and a second dielectric film made of Nb_2O_5.

7. (Previously presented) A projection screen, comprising:

a substrate; and

a light selective reflection layer which is formed on one side of the substrate, which has reflection characteristics in relation to lights in specific wavelength bands, and which has absorption characteristics in relation to lights other than the lights in the specific wavelength bands, wherein the light selective reflection layer is an optical multilayer film made by alternately layering metal films and dielectric films, and wherein the light selective reflection layer is made by sequentially layering a first metal film made of Al, a first dielectric film made of Nb_2O_5, a second metal film made of Nb, and a second dielectric film made of Nb_2O_5.

8.-27. Canceled

28. (Previously presented) A method of manufacturing a projection screen, comprising a step of forming a light selective reflection layer having reflection characteristics in relation to specific wavelength bands and having absorption characteristics in relation to lights other than the specific wavelength bands lights on a substrate by using spattering, wherein the light selective reflection layer is an optical multilayer film made by alternately layering metal films and dielectric films, wherein the light selective reflection layer is made by sequentially layering a first metal film made of Nb, a first dielectric film made of Nb_2O_5, a second metal film made of Nb, and a second dielectric film made of Nb_2O_5.

29. (Previously presented) A method of manufacturing a projection screen, comprising a step of forming a light selective reflection layer having reflection characteristics in relation to specific wavelength bands and having absorption characteristics in relation to lights other than the specific wavelength bands lights on a substrate by using spattering, wherein the light selective reflection layer is an optical multilayer film made by alternately layering metal films and dielectric films, wherein the light selective reflection layer is made by sequentially layering a first metal film made of Al, a first dielectric film made of Nb_2O_5, a second metal film made of Nb, and a second dielectric film made of Nb_2O_5.

30.-44. Canceled